



Powering Innovation That Drives Human Advancement

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# Innovating Semiconductor Manufacturing with ML-augmented Digital Twins

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# Agenda

**Challenges of Digital Twin in Semiconductor Manufacturing**

Emerging Digital Twin and Co-optimization Technologies

Manufacturing Digital Twin in Omniverse and Use Cases

Summary

# Digital Twins for Semiconductor Manufacturing Requires Partnerships

- NSTC Funding one Digital Twin Manufacturing Institute at \$285 million over 5 years as consortium of universities and companies from US Chip Act
  - [CHIPS for America Announces \\$285 Million Funding Opportunity for a Digital Twin and Semiconductor CHIPS Manufacturing USA Institute | NIST](#)
- Rockwell and NVIDIA provide process automation tools, and DT models of factories with the Industrial Metaverse: Emulate3D, FactoryTalk, Omniverse
- MSFT and AWS provide IOT connections and compute on the cloud for data-analytics based Digital Twins: AzureTwin, AWS Twinmaker
- Equipment and Foundry companies like Applied Materials, Lam Research and TSMC can create Digital Twin models of their equipment, e.g. Applied Twin
- Ansys, PTC, Autodesk, etc. could provide simulation-based digital twins and hybrid (AI plus physics) digital twins
- Ansys is one of the 8 founding members of the digital twin consortium



## Semi Digital Twin ECO Partners



# SoC/3DIC Manufacturing Process Overview



# Film Forming - PECVD

## • Engineering Goals

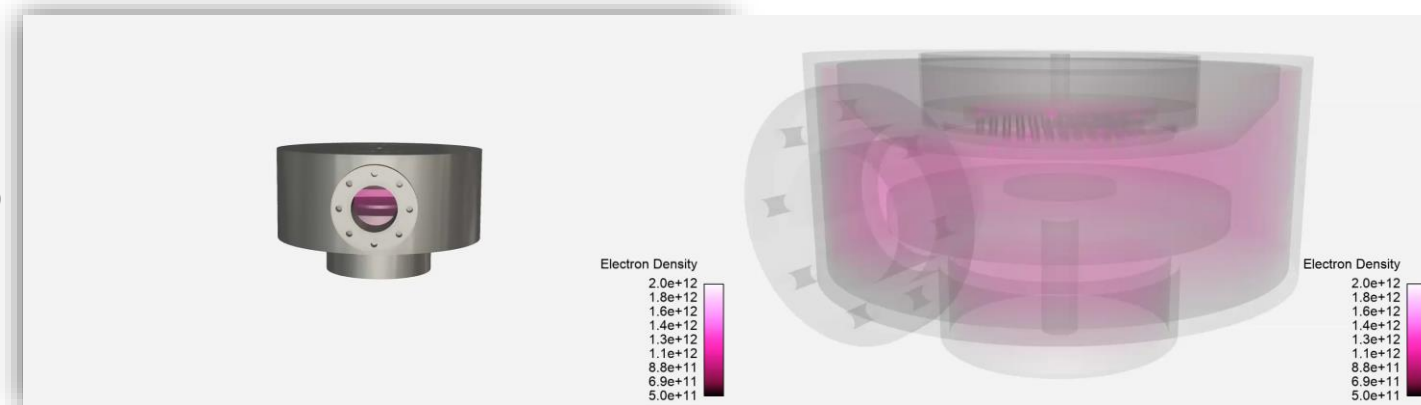
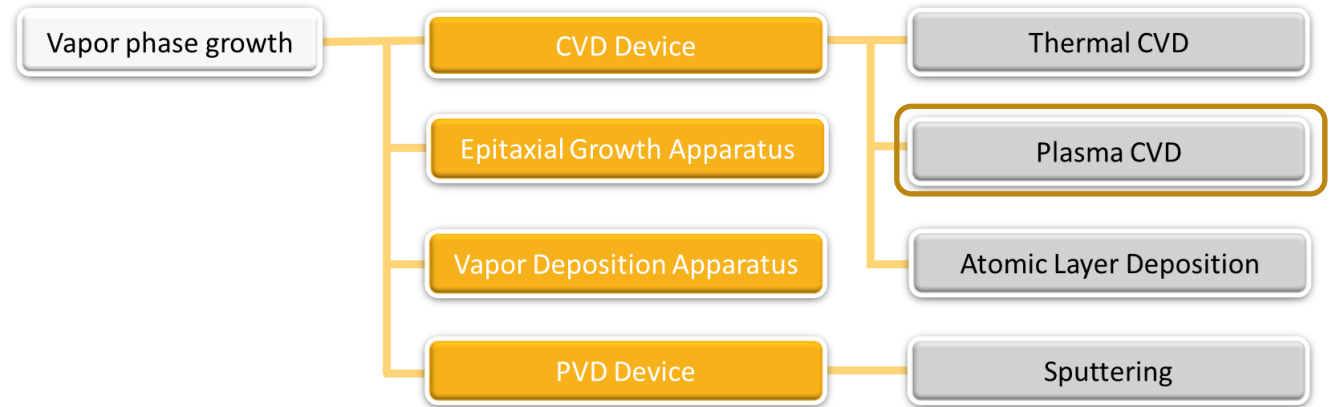
- **Uniform** flow and temperature distribution for accuracy of film thickness across wafer
- **Prevents** particle generation defects in the chamber
- **Predict** non-uniformity of process results due to manufacturing equipment

## • Multiphysics Solutions

- **Chemkin Pro:** reaction mechanisms, material properties, etc.
- **EMA3D and Fluent solvers:** Species transport, surface reaction considering the particle physics effect for plasma dynamics
- Multiphysics simulation with ROMs considering time-domain electrostatics, electromagnetics, particle in cells (PIC) and CFD
- Native GPU-enabled fast CFD and mechanical solvers

## • Benefits

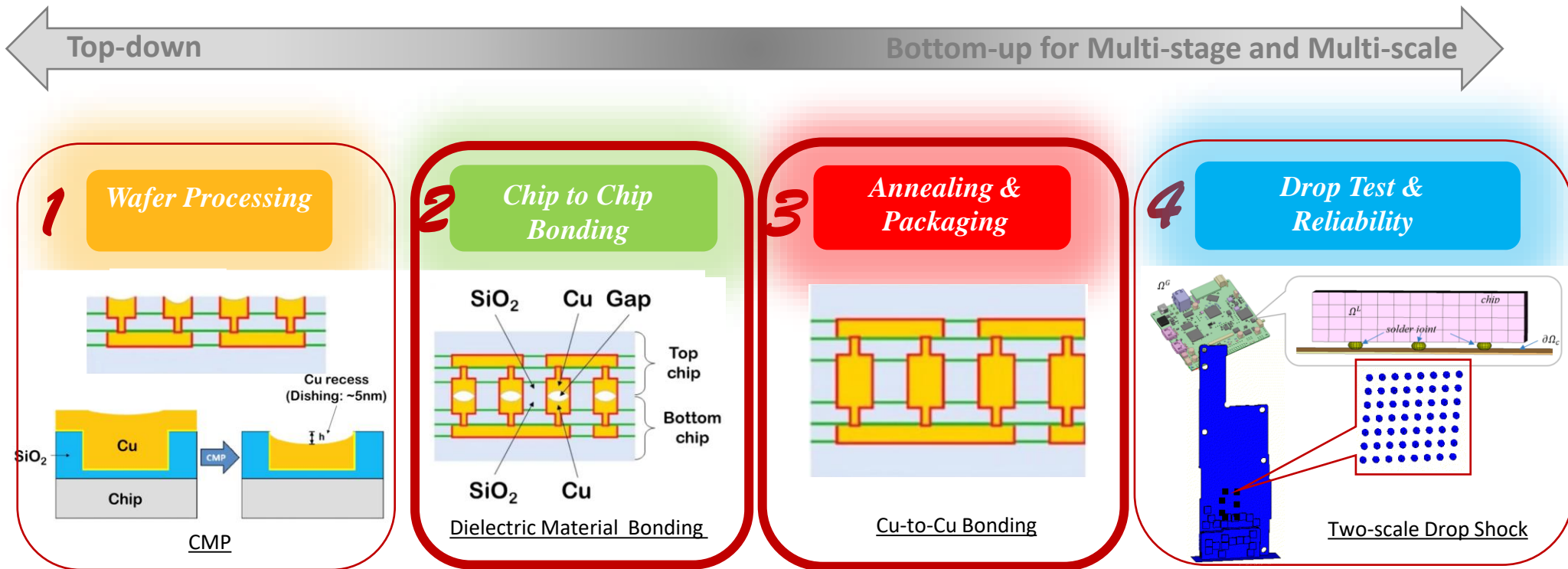
- **Improve** product quality and yield rate by optimizing design of equipment and process
- **Save** engineering cost and **reduce** rework





# 3DHI Process Simulation – CMP and Hybrid Bonding

- ❑ CMP analysis followed by adhesion between layers (e.g. Hybrid Bonding ) simulation is in a pressing need



“Integrated Process-mechanical Stress Analysis of 2.5D/3D ICs with Two Types of Interconnections in Advanced Packaging”, B. Ren, N. Chang, et al., IIRW, 2023

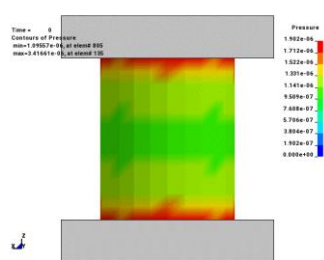
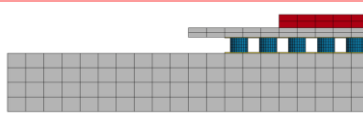
# ML-based Multiscale Framework for Solder Joints Reliability

- Incompressible Smoothed Particle Galerkin (ISPG) Method and Two-scale Co-simulation (TSC) were developed in LS-DYNA to meet this need.

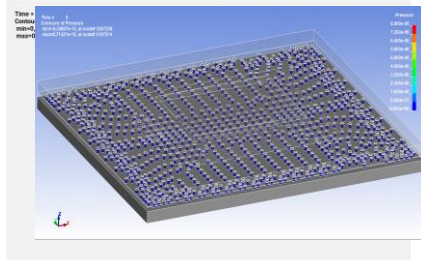
## Manufacturing-informed Multi-scale Framework

### Chip-Scale Solder Reflow Simulation by ISPG Technology

#### *Solder Reflow & Packaging*



Single Solder Reflow



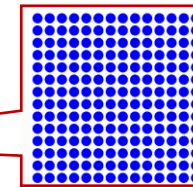
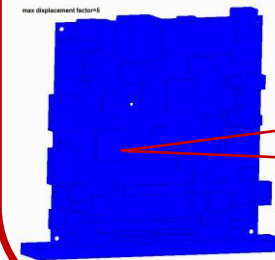
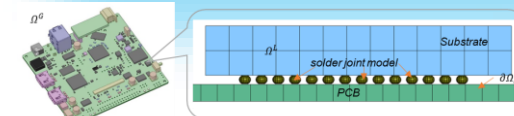
Reflow of 2000 Solder Balls

Immerse Modeling  
Thermal-induced PCB  
Warpage

Mask and Pad  
Geometry  
Dissimilar Solder Ball  
Shapes

### Two-scale Dynamic Shock Wave Simulation by TSC Technology

#### *Drop and Shock Tests*



Linking Chip- and System-Scale  
in Drop Shock Simulation

Wei H., Wu CT, Hu W., Su TH., et al. (2023). "Machine Learning-based Multi-scale Simulation of Composite Materials with Applications to Electronics Drop Tests", *Journal of Engineering Mechanics*.

# Semiconductor Manufacturing Process Overview

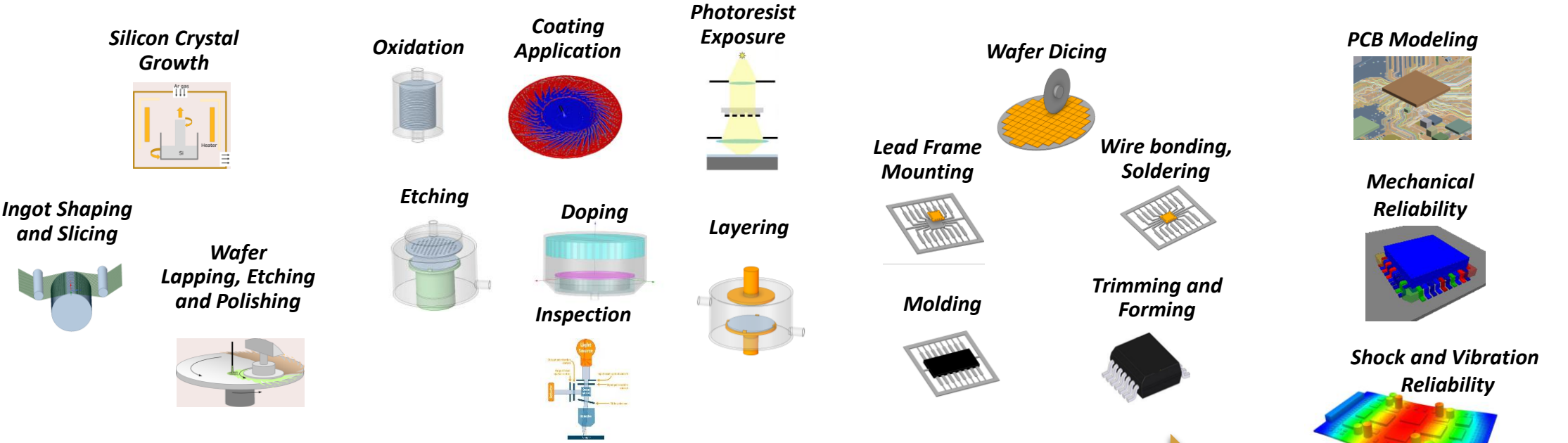


Blank Wafer Production

Semiconductor Fabrication

Assembly & Packaging

Printed Circuit Board  
Assembly & Testing



Raw Silicon Producers

Equipment Manufacturers and Chip Factories

Outsourced Assembly & Testing

PCB Manufacturers



# Agenda

Challenges of Digital Twin in Semiconductor Manufacturing

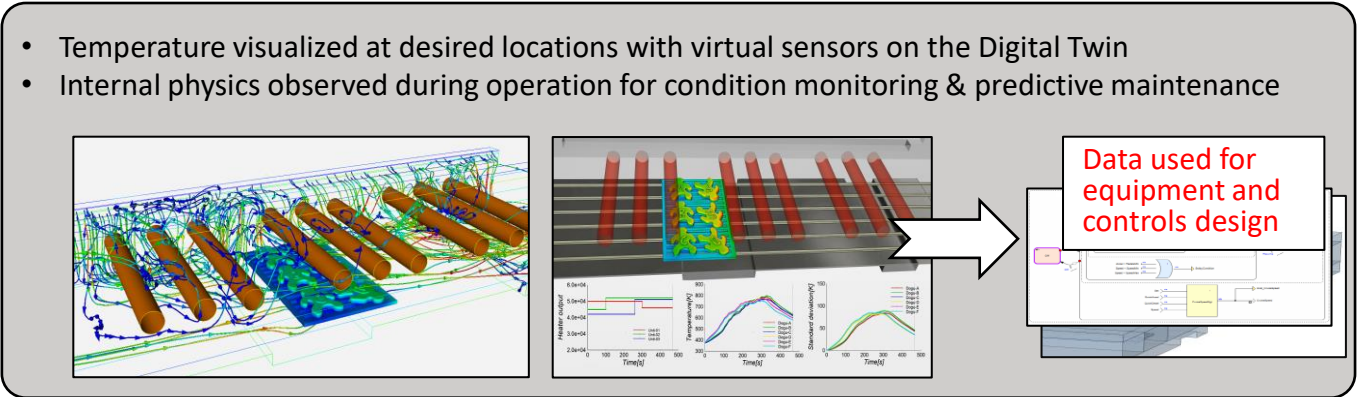
Emerging Digital Twin and Co-optimization Technologies

Manufacturing Digital Twin in Omniverse and Use Cases

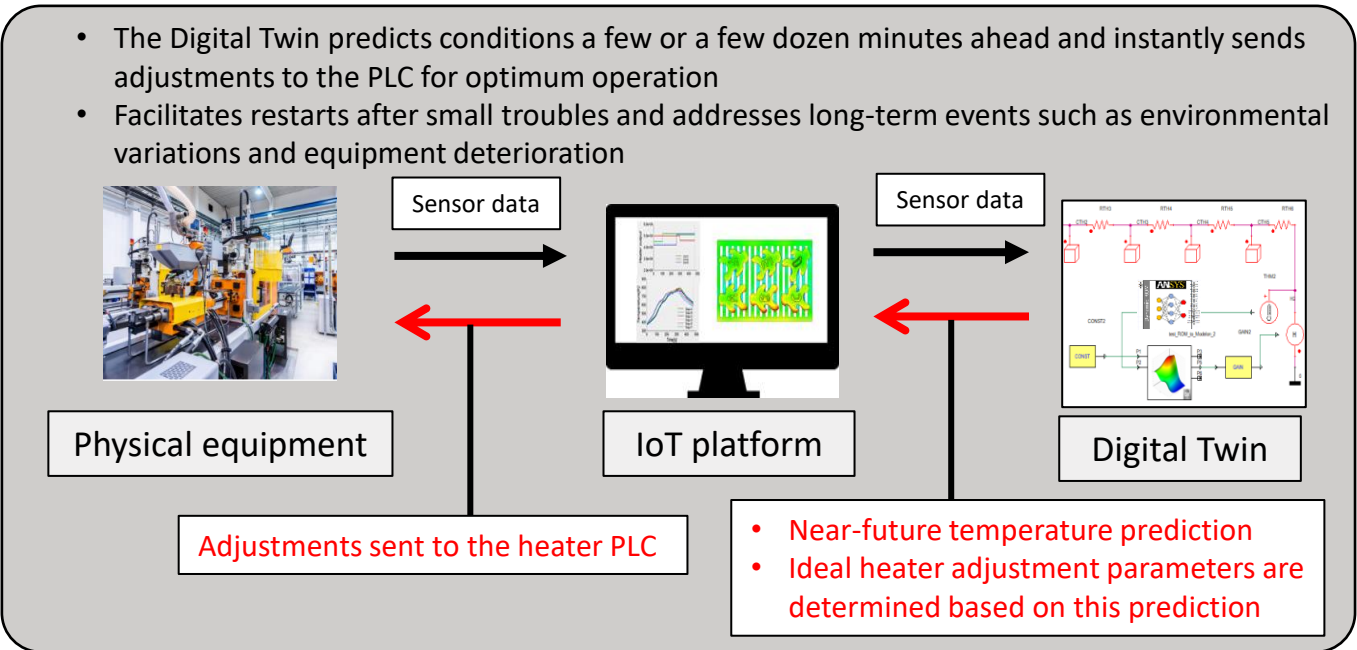
Summary

# Overview of Digital Twin

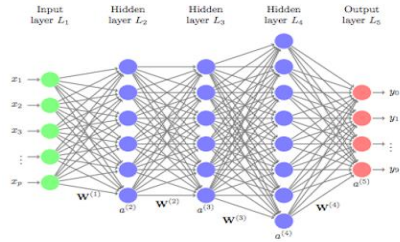
- Ansys physics-based Digital Twins virtually emulate production line equipment with fidelity and synchronize the virtual and physical systems to address challenges arising in the production line



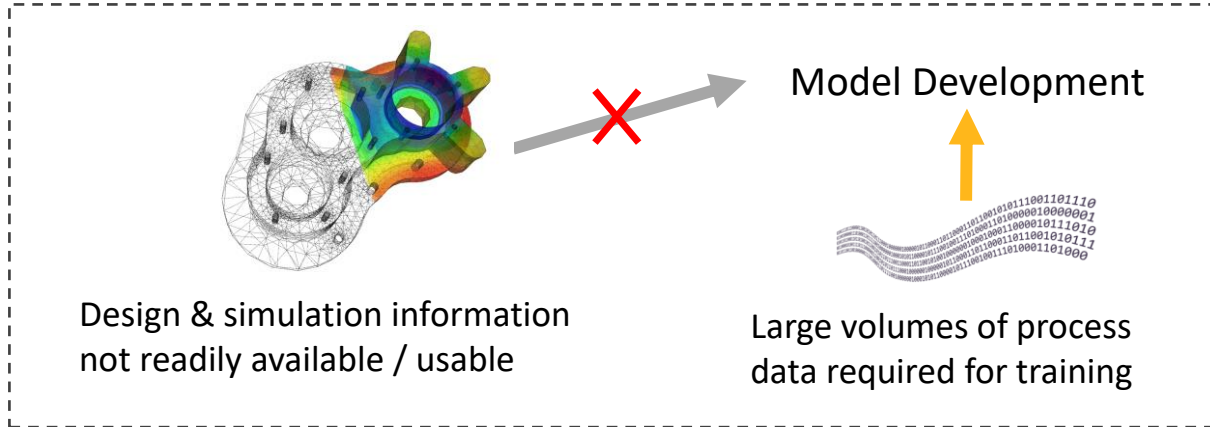
- Digital Twin benefits
  - Predictive and prescriptive maintenance
  - Equipment and operation optimization
  - System construction and troubleshooting
- Challenges expected in production lines
  - Shorten the line startup period
  - Improve the yield rate
  - Trace the causes of defect and manage data
  - Operate efficiently and autonomously



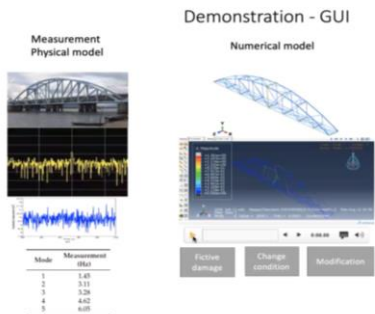
# Digital Twin Challenge: Accuracy, Time & Cost



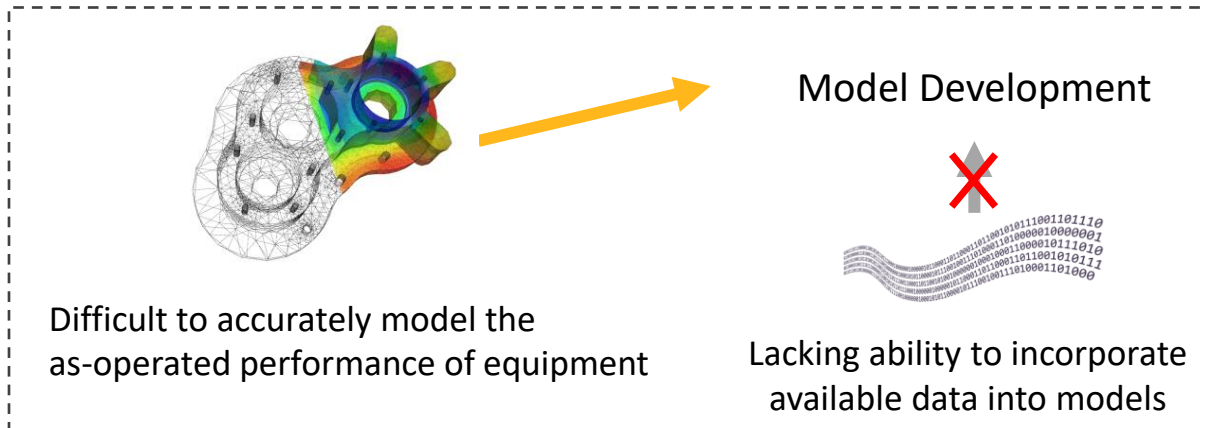
**Data-Driven Modeling**



**Insufficient accuracy, limited by observed data**



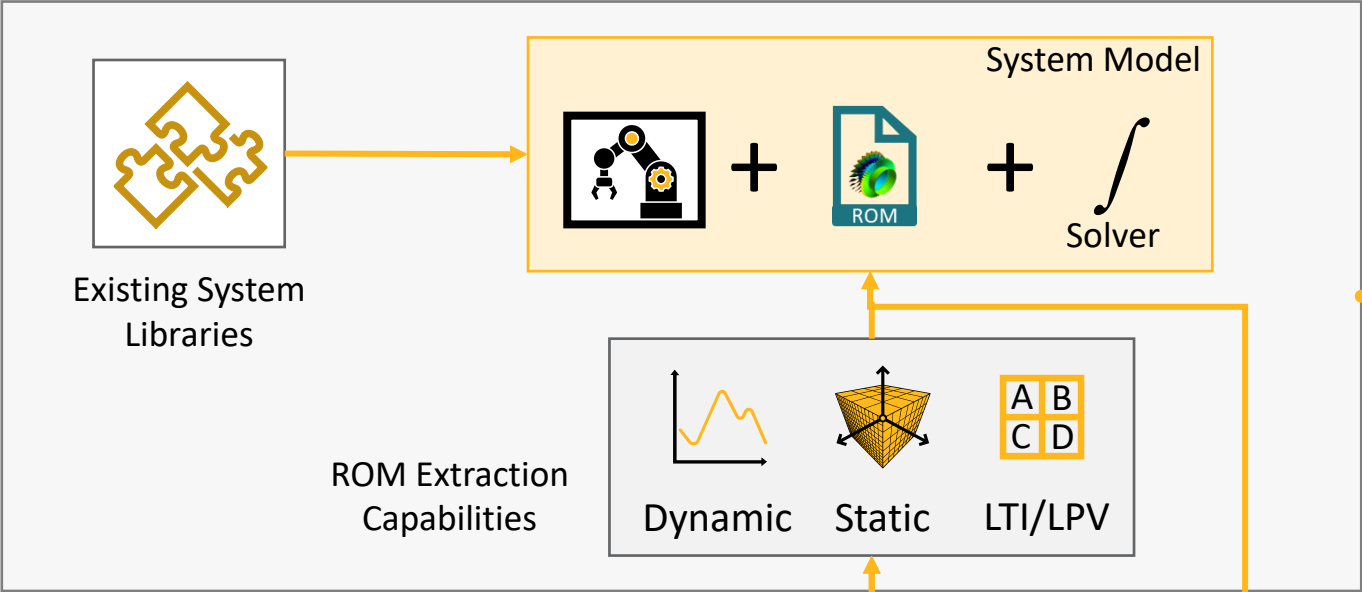
**Simulation-Based Modeling**



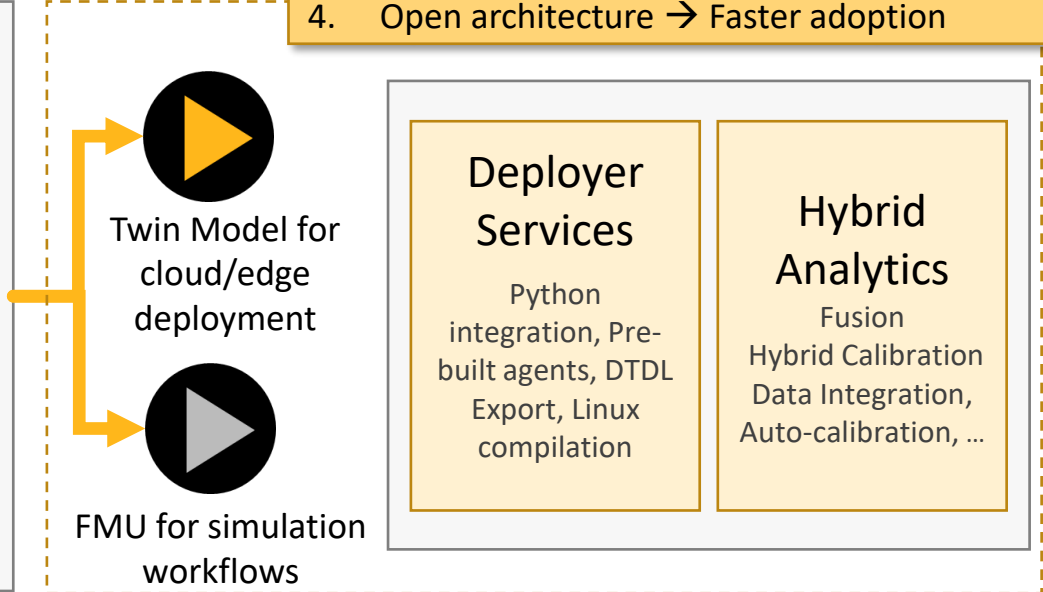
**Long, expensive time scales to develop & deploy**

# Ansys Digital Twin Architecture

## Twin Builder & TwinAI



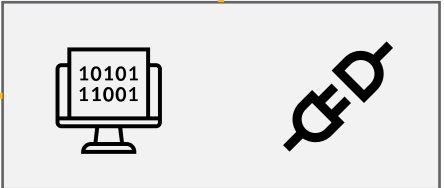
1. Hybrid Calibration → Most accurate Twin
2. Best in class ROM capabilities → Easy Reuse
3. Unique runtime model → Easy Scalability
4. Open architecture → Faster adoption



## Twin Deployer



Validated Ansys Physics

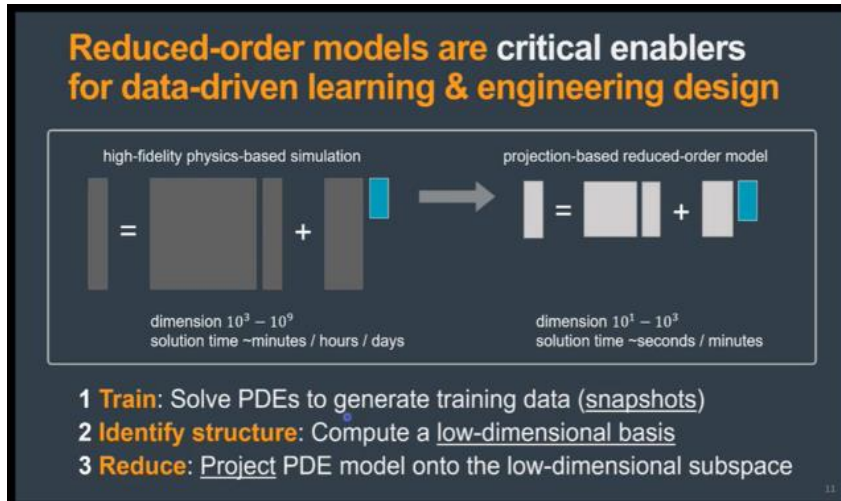


Test Data, 3rd Party Software



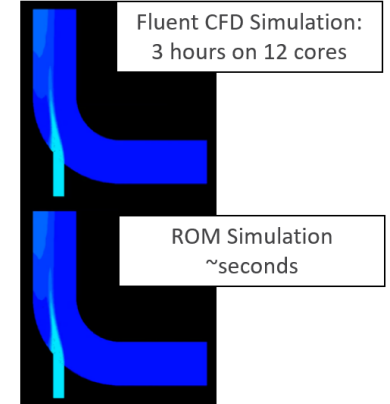
Open Ecosystems and Key Announced Partners

# Reduced Order Models (ROM) in Hybrid Digital Twin

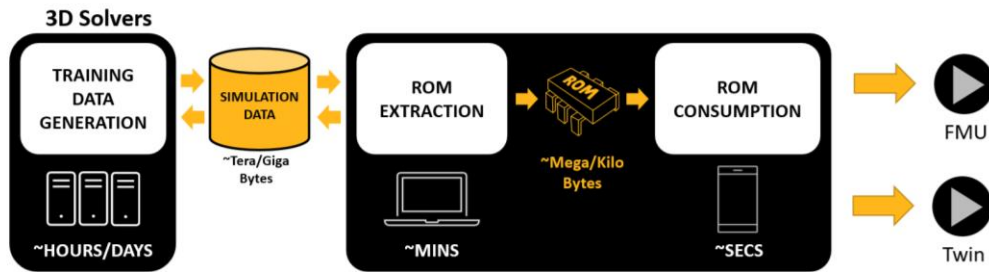


ROMs are compact, auto-generated representations of full-3D models that are useful for control design/validation

- ROMs are usually compute and license intensive to create but fast once built
- ROMs have well-defined inputs and outputs (electrical ports, parameters, etc)
- ROMs match the steady-state and/or dynamic responses of the original model, within specified tolerance
- Benefits
  - Reuse: Easily and automatically generate accurate & validated component models
  - Process Compression: Simulate accurate models in 1/10<sup>th</sup> to 1/100<sup>th</sup> of the time
  - System Verification and Optimization: Perform rapid design optimization and tradeoff analysis at system level



## ROM Generation Workflow



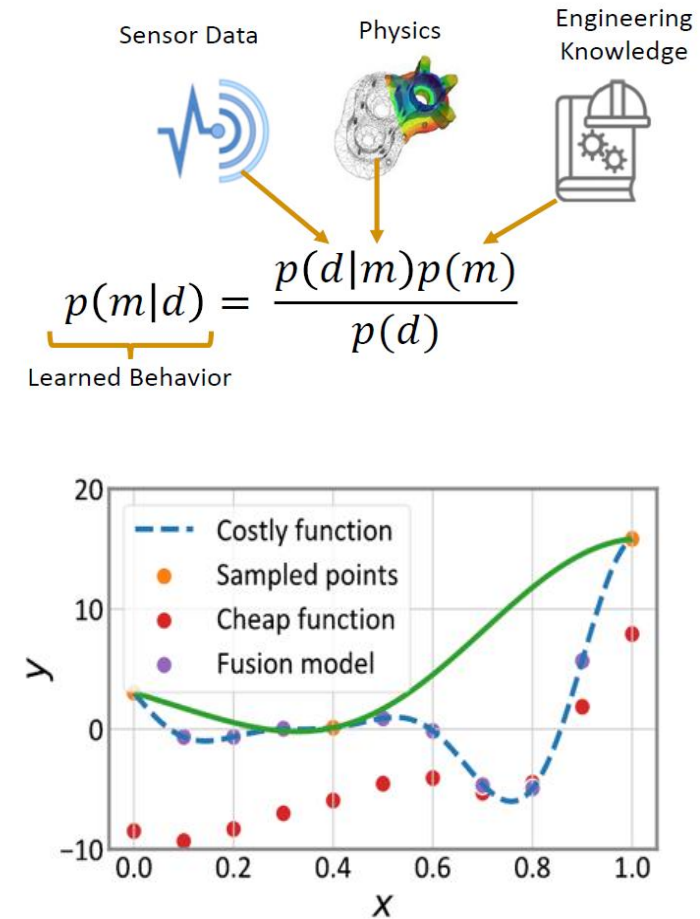
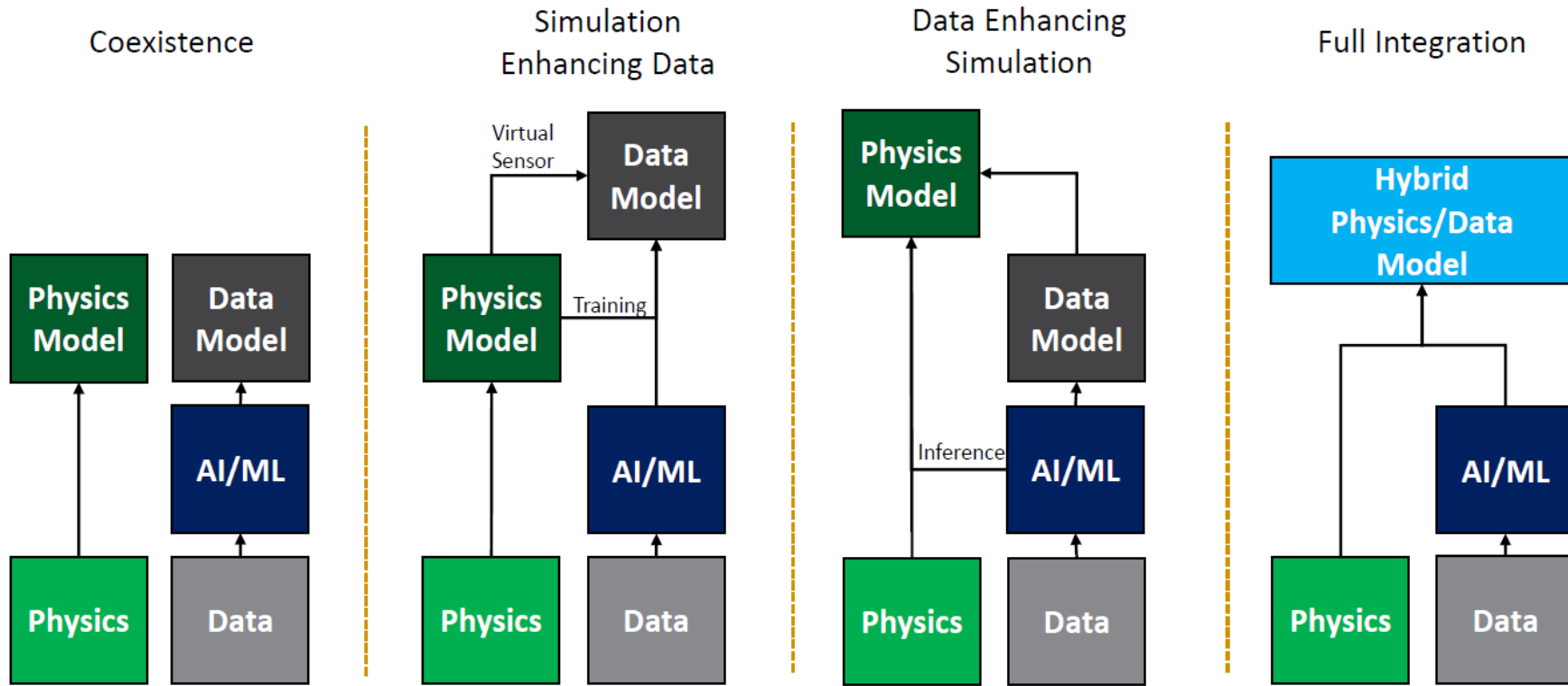
- All ROMs can be exported as FMUs for use in other tools for scalar inputs and outputs
- ROMs with field inputs/outputs are exported in a proprietary Ansys format (Twin)

ROM Type	Training Data Generation		ROM Extraction		Consumption Format	Ease of Use	Complexity
	Type of Data Required	Source Tools	ROM Technique	Tools			
Response Surface	Parameter Sweep/DoE	All/Any	Lookup table + interpolation	OSL, MC, TB	FMU for Scalars, Twin for Fields	Integrated end-to-end workflow	No states/steady-state only
LTI/LPV/State-space ROMs	Response to step inputs	Mech, CFD and EM	State-space Model with Interpolation	TB, Fluent	FMU for Scalars, Twin for Fields	Mostly integrated. Manual transfers.	Linear or weakly non-linear and stateful
DynaROM	Response to various input waveforms	All/Any	Nonlinear ODE	TB	FMU for Scalars, Twin for Fields	Experience needed to generate training	Non-linear and stateful

OSL : optiSLang    MC : Model Center    TB : Twin Builder    FMU : Functional Mockup Unit

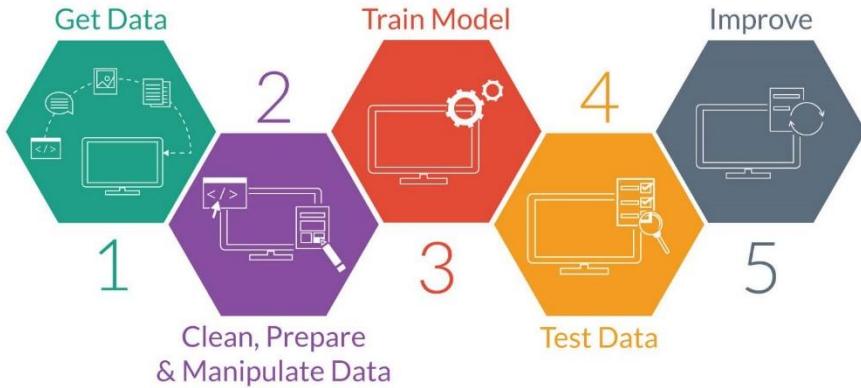


# Enabling ML-augmented Hybrid Digital Twin



M. Adams et al. - Hybrid Digital Twins: A Primer on Combining Physics Based and Data Analytics Approaches - IEEE Computer Society, 2022

# Auto-ML Framework Needed for System Technology Co-optimization



Adaptive Meta-Model of Optimal Prognosis (AMOP) for scalar values:

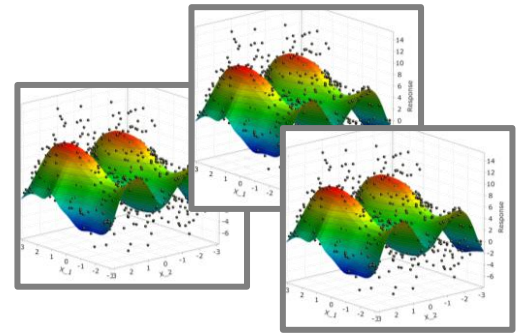
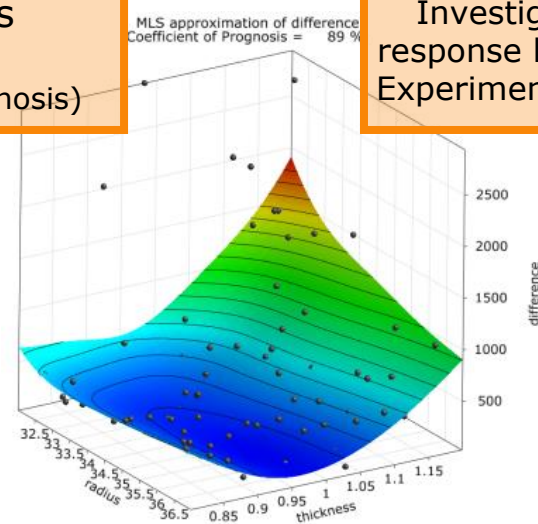
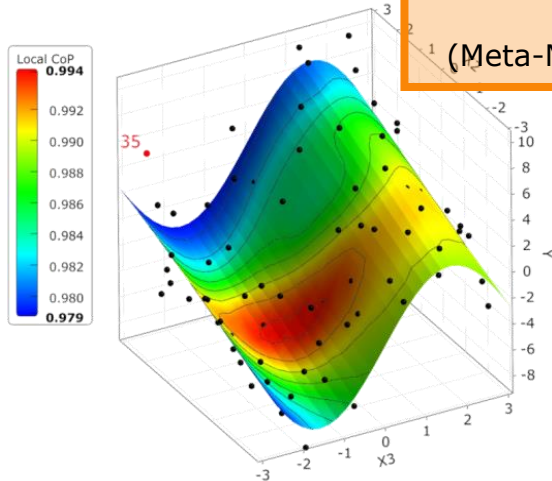
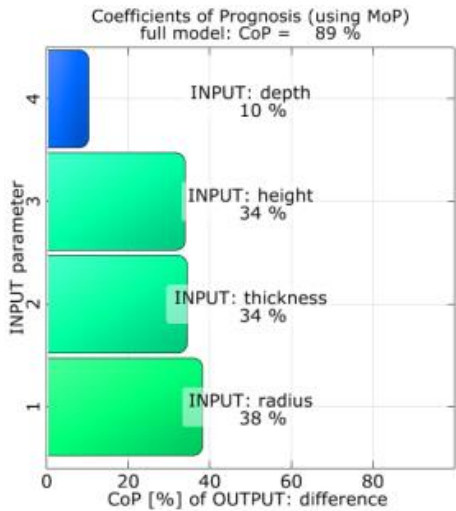
- Objective measure of prognosis quality = Coefficient of Prognosis (CoP)
- Determination of relevant parameter subspace
- Determination of optimal approximation model
- Approximation of solver output by fast surrogate model without over-fitting
- Evaluation of variable sensitivities

Calculate forecast quality using **CoP** (Coefficient of Prognosis)

The winner is ... **MOP** (Meta-Model of Prognosis)

Investigate response by response based on Design of Experiments (DOE) sampling

Generate competing meta-models



# Agenda

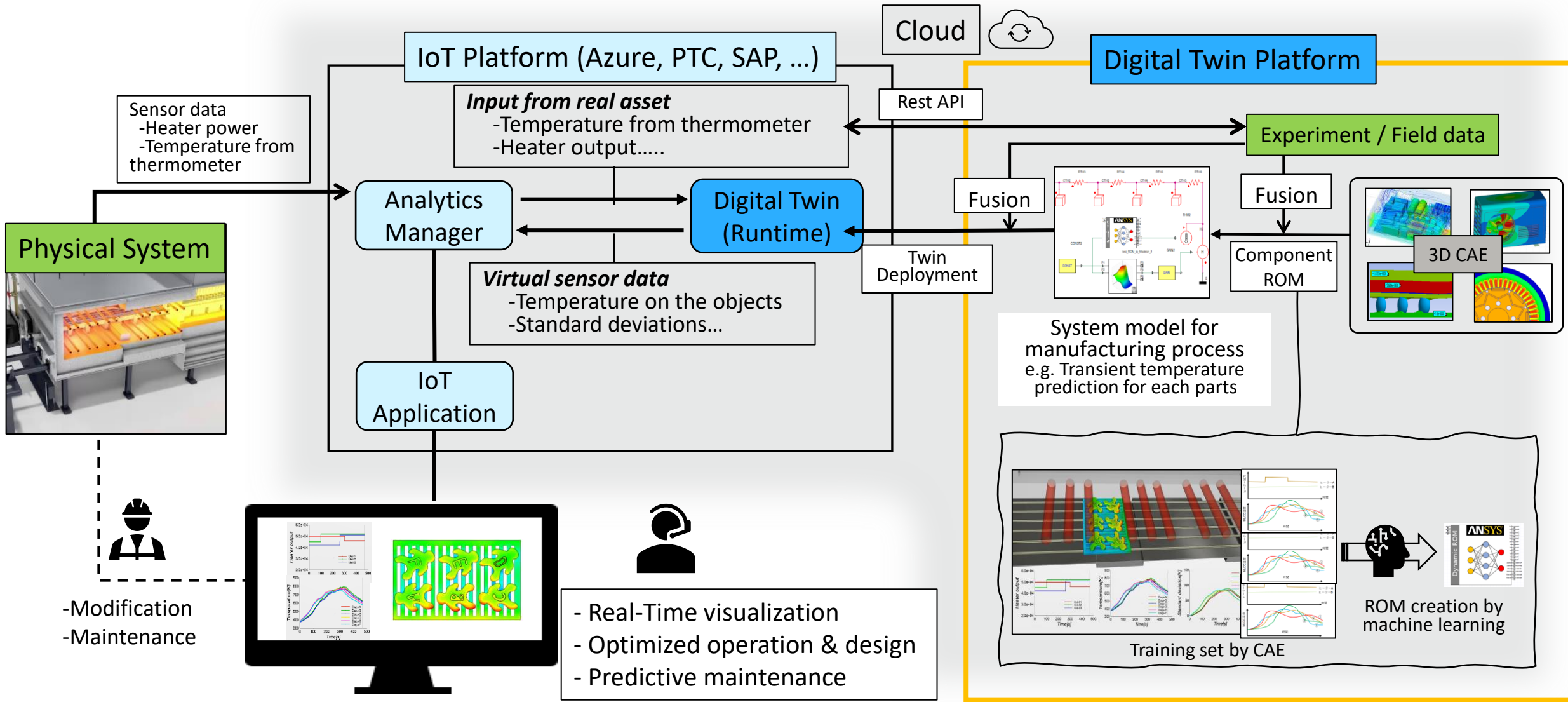
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Summary

# ANSYS Digital Twin for *Manufacturing Process*



# Digital Twin for Thermal Issue in Data Center

## Challenge

- The growing energy consumption in data center is a serious issue. Effective cooling of the data center is a key factor to reduce it, because over 30 % of the energy consumption is from the cooling system.
- Digital Twin operations in real-time for thermal-flow distribution help the optimal operations.

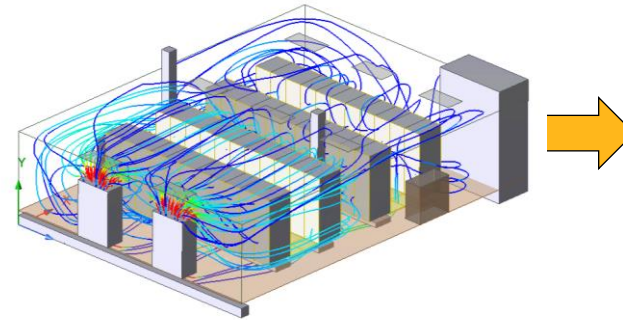
## Solution

- Quick training data creation with various operating conditions for Static ROM & LPV ROM by 3D CFD on **AEDT Icepak**.
- Validated ROM in **Twin Builder** can be exported via **Twin Deployer** to visualize the temperature fields and the point variables as virtual sensors with dynamics. **PyTwin** helps its deployment.

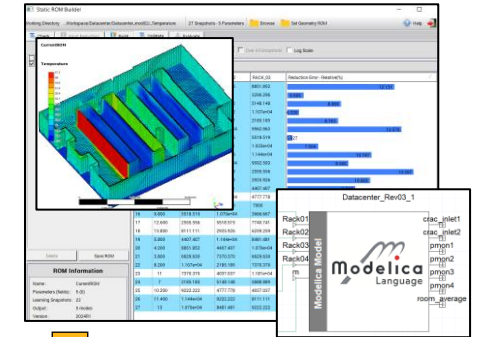
## Benefits

- Digital Twin of data center offers:
  - ✓ **Real-time visualization** to identify thermal issues.
  - ✓ **Immediate alerts** for swift operator response.
  - ✓ **What-if analysis** for strategy development and scenario planning.
- Digital Twin enables the optimal operations, reduction of energy consumption and risk management for Data center.

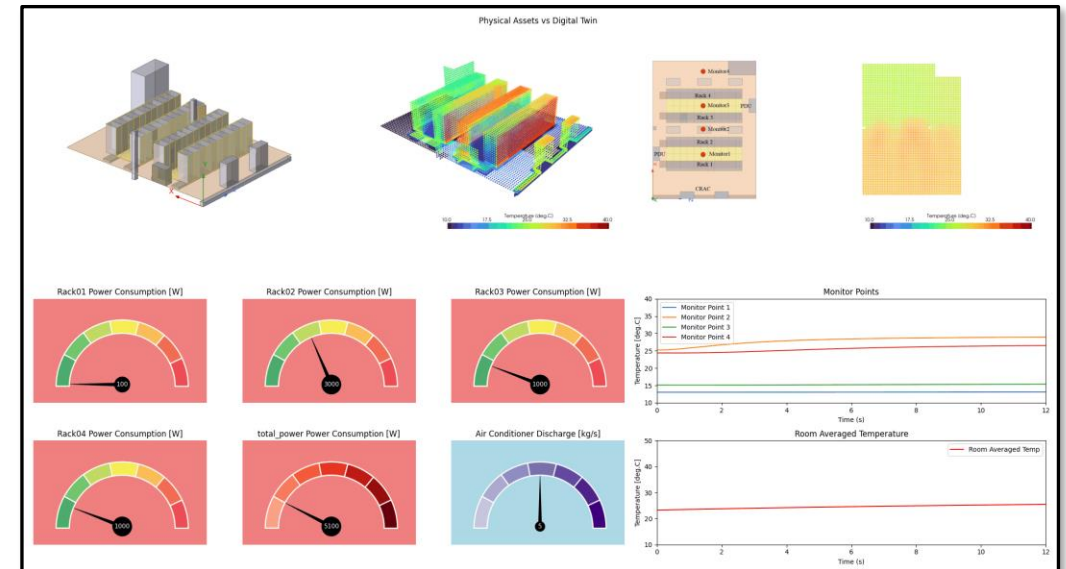
## 3D thermal flow simulations



## Model creation & validation



## Twin Deployment & real time visualization





# optiSLang Workflows + 3D ROMs for Virtual Digital Twin

- 3D ROM function as a virtual twin in a browser-based app
- Able to extract 3D field-data (temperature) out of Icepak
- Prediction quality of 3D field-data is checked and sufficient
- Receive real-time measurements (5-8 thermocouples) and fit/predict to whole corresponding temperature distribution in 4 seconds
- Wide audience of laboratory workers can benefit
- Enables rapid assessment on demand immediately
- A **robust optimal design** can be found early in the process

## Digital Twin

Pros and cons of Test and Simulation

### TEST DEVICE

- Real Product used
- Measurement itself is in real-time
- Result reliability is huge

### But:

- Physical modification of the product
- Limited measurement points

### SIMULATION MODEL

- Parametric modelling
- Based on virtual data early in the process
- High resolution

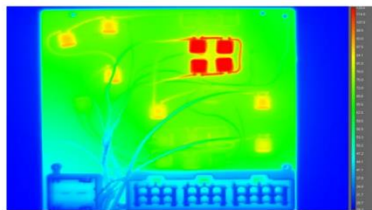
### But:

- Dependent on the accuracy of simulation model and the chosen input parameters.

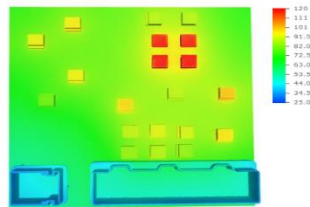
› The **Digital Twin** combines the advantages of test and simulation, eliminating their disadvantages.

## Digital Twin

Comparison IR Picture & Digital Twin



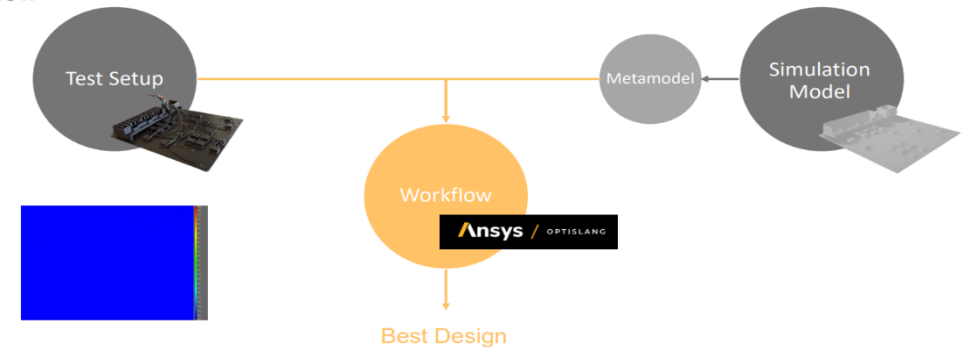
Test Setup - IR Picture



Digital Twin Result

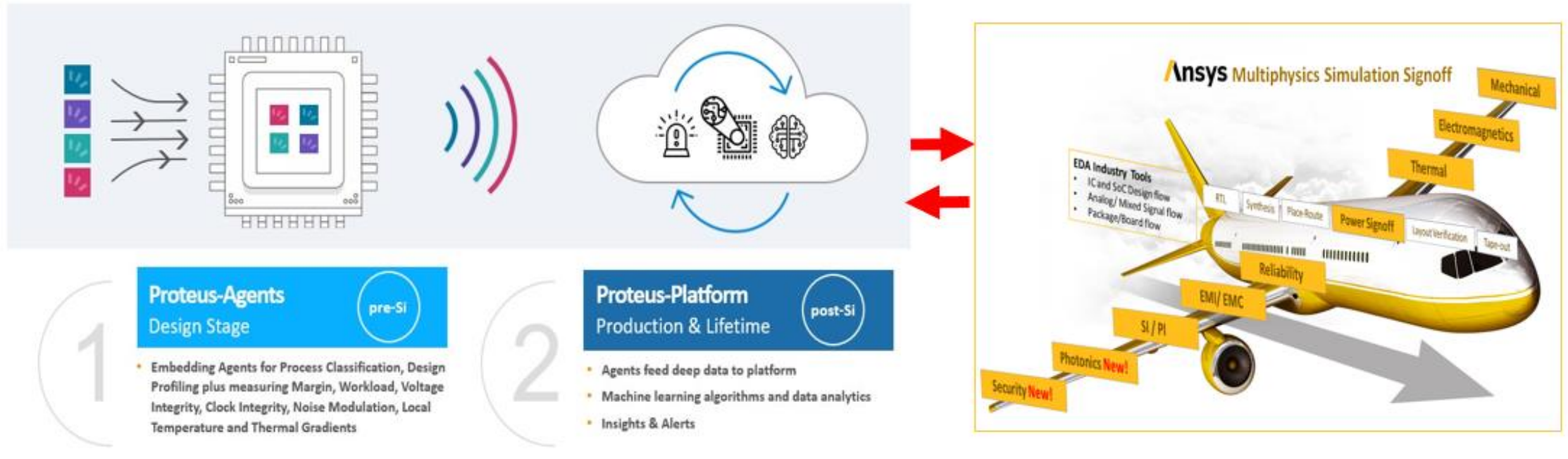
## Digital Twin

Workflow



Thermal Digital Twin & Virtual Build: A new approach of understanding systems, Laura Lindner, Continental GmbH, WOST2023,

# Emerging Model-based Digital Twins with On-chip and System Monitoring Solution (e.g. proteanTecs, MoorTec/Synopsys, and PDF)



Key benefits for the application-specific reliability monitoring and digital twins

- Model-based digital twins for application-specific reliability such as aging/wear-out prediction for predictive maintenance with Lifetime Electronics Monitoring
- Can root-cause PI/SI/TI issues during testing/field w/ multi-physics simulation
- Provide on-chip agents feedback on the design with application-specific reliability information
- Optimal locations of on-chip agents can be provided by multi-physics simulation solutions for Thermal/DvD/Workload/Timing, etc.

# Integration with Nvidia Omniverse for Digital Twin Deployment

- Digital Twins runtimes can be executed with Omniverse
  - Input values defined through constant, time series, or streamed from real world
- Results, including 3D ROM visualization can be rendered in Omniverse, and combined with other capabilities of the platform with scene definition, AR/VR, and cloud deployment/streaming, etc.



# Summary

- A robust Hybrid Digital Twin solution is needed that combines the benefits of physics-based simulation with data-based ML techniques to create accurate, evolving representations of real-world assets
- Multiphysics simulation is key to Digital Twin implementations, providing critical capabilities such as virtual sensors, what-if analysis, causality and failure mode analysis
- Hybrid digital twin enables the reuse of existing simulation models (via ROMs, optiSLang, and customized ML solutions), typically created during product design, and makes them fit-for-use during manufacturing operations in combination with measurement data
- ML-augmented Hybrid Digital Twins can be used for Semiconductor Manufacturing real-world use cases

# Acknowledgement

- Thanks to Sameer Kher, Matt Adams, Kalyan Sharma, Srinivasa Mohan, Nima Arkhazloo, Akira Fujii, Bo Ren, CT Wu, and Prith Banerjee for the discussion on hybrid digital twin
- Thanks to Haiyan He, Akhilesh kumar, Jie Yang, Wenbo Xia, and Lang Lin on the discussion of on-chip thermal digital twin



The Ansys logo consists of a yellow slanted bar followed by the word "Ansys" in a bold, black, sans-serif font.

